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ISSUE CLASSIFICATION	Class	Subclass

PATENT NUMBER

U.S. **UTILITY** Patent Application

O.I.P.E.	PATENT DATE
SCANNED FK3 Q.A. AM3	

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/853345		360 430	313 319	~~2651~~ 1752	~~Renner~~ McPherson

APPLICANTS

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TITLE

Fully undercut resist systems using e-beam lithography for the fabrication of high resolution MR sensors

PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)	
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)
INTERNATIONAL CLASSIFICATION			
			☐ Continued on Issue Slip Inside File Jacket

☐ TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
☐ The term of this patent subsequent to _____ (date) has been disclaimed.				NOTICE OF ALLOWANCE MAILED	
	_____ (Assistant Examiner)		_____ (Date)		
☐ The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____				ISSUE FEE	
				Amount Due	Date Paid
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☐ The terminal ___ months of this patent have been disclaimed.				ISSUE BATCH NUMBER	
	_____ (Legal Instruments Examiner)		_____ (Date)		

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